

The Polysurface Mechanism of Ta and Ti Anodic Dissolution in Low-Temperature Carbamide-NH₄Cl Melt

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Z. Naturforsch. **56 a**, 761–763 (2001); received August 8, 2001

Presented at the NATO Advanced Study Institute, Kas, Turkey, May 4 - 14, 2001.

In this work the peculiarities of the electrochemical dissolution of tantalum and titanium in carbamide containing low temperature melts were studied.

Key words: Carbamide; Tantalum; Titanium; Electrochemistry; Passivation.